



Docket No.: 50432-067

PATENT

#18
10803
WJS

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Customer Number: 20277
Kai YANG, et al. : Confirmation Number: Not Yet Assigned
Serial No.: 09/817,056 : Group Art Unit: 2811
Filed: March 27, 2001 : Examiner: T, NGUYEN
For: STABILIZING FLUORINE ETCHING OF LOW-K MATERIALS

TC 2300 MAIL ROOM
CCT - 2 2103

RECEIVED

INFORMATION DISCLOSURE STATEMENT

Mail Stop Information Disclosure Statement
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the references listed on the attached form PTO-1449. It is respectfully requested that the references be expressly considered during the prosecution of this application, and that the references be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

The Morand et al. reference is believed to be an English language equivalent of the French Patent No. 2,798,512 A1 previously submitted in the Information Disclosure Statement

09/817,056

filed November 25, 2002. A copy of the International Preliminary Examination Report is attached for the Examiner's information.

Please charge any shortage in fees due in connection with the filing of this paper, including extension of time fees, to Deposit Account 500417 and please credit any excess fees to such deposit account.

Respectfully submitted,

MCDERMOTT, WILL & EMERY


Arthur J. Steiner
Registration No. 26,106

600 13th Street, N.W.
Washington, DC 20005-3096
(202) 756-8000 AJS:men
Facsimile: (202) 756-8087
Date: October 1, 2003

***EXAMINER:** Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

1 Applicant's unique citation designation number (optional). 2 A

1 Applicant's unique citation designation number (optional). 2 Applicant is to place a check mark here if English language Translation is attached.